# Electrochemical Growth of Superconducting Rhenium

### **Purpose and Objectives**

- In this research project, we designed an experimental apparatus to grow rhenium films.
- Transport measurements were performed on the films to test their superconducting properties, such as the superconducting transition temperature  $T_c$ .
- Rhenium has applications in ultra-low temperature quantum computers. It has an advantage to the typical metals used because it is resistant to oxidation and therefore is easier to solder [1].
- Electrodeposition allows for growth directly onto patterned circuits, making them superconducting.

### Background

#### Type I and Type II Superconductivity

- Superconductivity exists when a material has no electrical resistance and expels magnetic field lines through it. This occurs when the material is cooled near absolute zero temperature.
- Type I superconductors will expel magnetic field when the applied magnetic field is below the critical value, H<sub>c</sub>.
- Type II superconductors have two critical fields, H<sub>c1</sub> and H<sub>c2</sub>, and can expel field lines completely under  $H_{c1}$ , and partially under  $H_{c2}$ .



Phase diagram for Type I and Type II superconductors [2]

#### Rhenium and its superconducting properties

- In its metallic form, rhenium (Re) is a well known Type I superconductor with a critical temperature of 1.8 K.
- It has been shown that when the Re lattice is put under shear strain, the material becomes a Type II superconductor with a critical temperature of over 3 K [1].
- This can be achieved by electroplating Re onto noble metals (Au, Cu, and Pd) [1].



Simulation of the Re-Au interface reveals shear strain in the Re lattice.



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## **Experimental Methods Electrochemical Deposition** • Electrochemical Deposition a method of depositing a thin film (usually a metal) onto a conductive substrate. • It relies on electrochemical oxidation-reduction reactions to deposit aqueous ions onto the surface of the substrate. • In this project, aqueous ammonium perrhenate (NH<sub>4</sub>ReO<sub>4</sub>) was used to deposit metallic rhenium onto a gold plated silicon substrate. • The perrhenate ion is reduced to solid rhenium by the oxidation-reduction reaction [3]. (1) $\operatorname{ReO}_4^- + 2\mathrm{H}^+ + \mathrm{e}^- \to \operatorname{ReO}_3 + \mathrm{H}_2\mathrm{O}$ (2) $\operatorname{ReO}_3 + 2\mathrm{H}^+ + 2\mathrm{e}^- \to \operatorname{ReO}_2 + \mathrm{H}_2\mathrm{O}$ (3) $\operatorname{ReO}_2 + 4\mathrm{H}^+ + 4\mathrm{e}^- \rightarrow \mathrm{Re} + 2\mathrm{H}_2\mathrm{O}$ (4) $\operatorname{ReO}^- + 8\mathrm{H}^+ + 7\mathrm{e}^- \rightarrow \mathrm{Re} + 4\mathrm{H}_2\mathrm{O}$ **Methods** • The solution consisted of 0.025 M ammonium perrhenate ( $NH_AReO_A$ ) and 0.1 M sulfuric acid ( $H_2SO_4$ ), for a pH of ~ 1. • Substrates were prepared using two different methods: • Method 1: The substrates consisted of a doped silicon base layer (3.5mm x 3.5mm), a titanium seed layer, and a top gold layer. A copper wire was attached to the substrate using silver epoxy. • Method 2: The substrates used the same silicon base layer, but the titanium/gold thin films were replaced with thermally evaporated copper films. This method uses more affordable, readily available materials. • A Pt-coated metal anode was used, and the substrate served as the cathode. • Growth was carried out at 10 mA, and the voltage at the cathode was approximately 0.6 V (relative to the solution). The solution was heated to 30 °C and stirred at 500 RPM. Cathode (-) Re<sup>+</sup> Si Substrate

Diagram of Electrodeposition setup used.

NH<sub>4</sub>ReO<sub>4</sub> Solution

Pt coated Sn



![](_page_0_Picture_25.jpeg)

![](_page_0_Picture_26.jpeg)

• The substrates prepared using evaporated copper failed to exhibit electrochemical • The substrates prepared using Au over a titanium seed layer successfully supported • For the successful films, a superconducting transition was measured using low temperature magnetometry (left image). The transition was too broad to accurately characterize the critical temperature. According to [1], thinner Re films may correct • Attempted to take electrical transport measurements to more precisely characterize the superconducting transition (right image). However, the measurements contained a large amount of noise, and the system failed to reach the necessary temperatures Resistance vs. Temperature 0.1176 -0.1174 -E 0.1172 -0.1170 -0.1168 -0.1166 -Resistance vs Temperature curve shows what may be the beginning of a superconducting transition. Note that the drop in R is only 0.001 ohms, thus it is unlikely that a superconducting transition is shown. • Attempted to produce Re/noble metal multilayers (as done by [1]). • First, thermally evaporated copper was used to serve as a mid-film, however • Next, sputtered Au was used in place of copper, however this did not improve • Determine the cause of Re failing to stick to certain metals such as copper. • Grow multilayers of Re and measure its effect on the superconducting transition [1]. D. P. Pappas, D. E. David, R. E. Lake, M. Bal, R. B. Goldfarb, D. A. Hite, E. Kim, H.-S. Ku, J. L. Long, C. R. H. McRae, L D. Pappas, A. Roshko, J. G. Wen, B. L. T. Plourde, I. Arslan, and X. Wu, "Enhanced superconducting transition temperature in electroplated rhenium", Applied Physics Letters 112, 182601 (2018) https://doi.org/10.1063/1.5027104

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